#### REMARKS

Applicants respectfully request amendment to the instant application under 37 C.F.R. 1.312 to include correction of a minor error relating to units therein. Specifically, the unit for sheet resistance is changed to " $\Omega$ /square" which is well known in the art. To support this knowledge, Applicants provide herewith an excerpt from a textbook "Semiconductor Devices" for the Examiner's consideration.

Entry, therefore, is believed to be fully appropriate under 37 C.F.R. §1.312 since no new matter is added by this amendment.

In the event that the Examiner has any questions relating to this Amendment or to the application in general, it would be appreciated if the Examiner would telephone the undersigned attorney concerning such questions so that prosecution of this application may be expedited.

In view of the above, entry of the same prior to issuance is respectfully requested.

Respectfully submitted,

Veffrey L. Costellia Registration No. 35,483

NIXON PEABODY LLP Suite 900 401 9<sup>th</sup> Street, N.W. Washington, D.C. 20004-2128 (202) 585-8000

# SEMICONDUCTOR **DEVICES**

## Mauro Zambuto

Department of Electrical Engineering New Jersey Institute of Technology

## BEST AVAILABLE COPY

# McGraw-Hill Book Company

New York St. Louis San Francisco Auckland Bogota Caracas
Colorado Springs Hamburg Lisbon London Madrid Mexico Milan
Montreal New Delhi Oklahoma City Pansma Paris San Juan São Paulo Singapore Sydney Tokyo Toronio

#### SEMICONDUCTOR DEVICES INTERNATIONAL EDITION

Copyright @ 1989

Exclusive rights by McCraw Hill Book Co. - Singapore for manufacture and export. This book cannot be re-exported from the country to which it is consigned by McGraw-Fill,

Copyright © 1989 by McGraw-Hill, Inc. All rights reserved. Except as permitted under the United States Copyright Act of 1976, no part of this publication may be reproduced or distributed in any form or by any means, or stored in a data base or retrieval system, without the prior written permision of the publisher.

1234567890 FSP PMP 89432109

This book was set in Times Roman. The editors were Alar E. Elken and John M. Morriss. The production supervisor was Denize L. Puryess. Project supervision was done by Santype International Limited.

### Library of Congress Cataloging-in-Publication Data

Zambuto, Mauro,

Semiconductor devices/Mauro Zambuto,

includes bibliographies and index.

ISBN 0-07-072700-7 (test).

ISBN 0-07-072701-5 (solutions manual)

1. Semiconductors. I. Title.

TK 7871.85.235 1989

621.36 '6-de19

88-1*6*369

When ordering this title use ISBN 0-07-190376-2

Printed in Singepore

DECT AVAILARIE COPY

Uni qua

picti fleld mair CORS

of th tan C New has c and t

quan Auck indus MASIL profe:



SEL

The intrinsic concentration is computed from (3.3.7): N\_ ≈ 220 cm²/(Y-s)

This is two orders of magnitude less than No. so the approximation of (11.11) holds  $R_{\rm s} = 3.65 \times 10^{14}$ 

concentration, the contribution of the holes to conduction is negligible, and the

M= (CIM)/(V·8)) ğ 킅 

STO BELLEVIE

Electron mobility in N-type Si vs. 1025

peratures, where the graph reaches a maximum before beginning to decay. peratures, following a T<sup>-30</sup> curve. In between there is a transition range of temgraph rises with T<sup>47</sup>. At high temperature, intrinsic, neutral atom collisions become the determining mechanism and the mobility drops with increasing temtemperatures, collisions with impurity ions are the prevalent mechanism and the 3 penture for arrent doping concessin-**(a)** 

concentrations, the position of the maximum is displaced toward higher and roughly the shape of Fig. 425. Notice that, as expected, with increasing depent higher temperature ranges. Example 4.2.2. The same specimen as in Example 4.2.1 is brought to a temperature

graph of Fig. 4.2.6 [9], in which each curve of constant deping is seen to follow

A more comprehensive picture of the phenomenon is given by the empirical

of 500 K. Compute the resistance and comment on the relative contribution of the

electrons and holes to conduction.

Solution. From Fig. 4.24, interpolating for  $N=1.9\times10^{17}$  cm $^{-3}$  and T=500 K:

and the minurity conter concentration is (261 × 102)

as this quantity is still 3 orders of anguitude analter than the majority carrier

conductivity can be computed on the basis of the electrons only:

0 ≈ 1.6 × 10-19(220 × 1014) = 0.35 1/12 cm

and finally:

0.35 × 10-1 × 2 = 284 Ω

# Sheef Registance

semiconductor material. Supposing the sheet has uniform thickness & and with In integrated circuits, resistors are often fabricated as thin sheets of catriagic 18,43 shown in Fig. 4.2.7a; then its resistance is

(4212)

If the resistor is square in shape, as in Fig. 427b, then L = w and (4212)

(4.213)

depends only on the thickness of the sheet and its average conductivity. square shape. The resistance of such square waters, indicated as  $R_D$  in (4.2.13), is resistance, independently of the size of the square, provided only they have a Notice that, for a given material and thickness, all square sheets have the same

resistance. Commercely, this method can be used to design the resistor. by counting the number of squares in the strip and multiplying by the sheet For the integrated circuit of Fig. 427c, the resistance can then be computed

3

PIGURE 427

then misson. A division into square to case comresistor of side L (c) Typical Linegrated execut Sheri resistance (a) Short resistor of purious putation of the total resistance is indicated by the doping, with w and distance & (b) Square shot

AVAILABLE COP